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Simulation and Experimental Study of Plasma Effects in Planar Silicon Sensors

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In silicon sensors high densities of electron-hole pairs result in a change of the current pulse shape and spatial distribution of the collected charge compared to the situation in presence of low charge carrier densities. This paper presents a detailed comparison of numerical simulations with time resolved current measurements on planar silicon sensors using 660 nm laser light to create different densities of electron hole pairs.

Keywords: silicon sensor, plasma effect, high charge carrier densities, simulation, pulse shape

Abstract

In silicon sensors high densities of electron-hole pairs result is of the collected charge compared to the situation in presence comparison of numerical simulations with time resolved collaser light to create different densities of electron hole pairs *Keywords:* silicon sensor, plasma effect, high charge carried stream of the detection of radiation. These sensors are built as p-n junctions operated under reverse bias. Electron hole pairs are created by ionization or direct excitation and induce a current in the electrodes when drifting in the electric field until they reach a contact. When the created charge carrier densities are sufficiently high to modify the electric field in the sensor, significant changes, compared to the situation with low charge carrier densities, are observed (so called plasma effects). These effects have been observed in the detection of heavily ionizing particles and with high intensity laser light.

Plasma effects are also expected for experiments at x-ray free electron lasers. The studies presented here aim at a quantitative understanding of the plasma effects for at a quantitative understanding of the plasma effects for at a quantitative understanding of the plasma effects form a so called plasma, which dissolves slowly. The plasma boundaries effectively shield its inner region from the external bias, thus altering the induced current pulse and increasing the charge collection time [2]. Plasma effects decrease as the electric field increases [3]. Using incident ions of different masses and energies, the influence of material properties on plasma effects has been studied in detail in [4].

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masses and energies, the influence of material properties 52 on plasma effects has been studied in detail in [4].

Electrostatic repulsion effects result in an increased lat- $^{54}\,$ eral spread of the collected charge and thus in increased 55 charge sharing between pixels, as shown for α -particles in 56 [5]. The effects on silicon sensors for the European XFEL 57

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were investigated using a focused high intensity laser to simulate x-rays in [6, 7].

In this work, simulation results are compared to measured current pulses showing plasma distortions after illumination with focused laser light of high intensity.

2. Experimental setup

Charge carriers were created with a laser of 660 nm wavelength and the time resolved current pulses of the investigated diode were read out by a Miteq AM-1309 wideband amplifier and a Tektronix DPO 7254 2.5 GHz oscilloscope.

The sample was mounted on a substrate that allowed light injection from both sides while providing a stable $(\pm 0.1 \text{ K, rms})$ temperature in the range of 240 K to 340 K and applying the high voltage to the rear side of the diode.

The systematic error of the determination of the number of generated electron hole pairs was estimated to be below 2% by injecting a defined charge into the readout system utilizing a defined test capacitance and a voltage step function.

2.1. Equivalent circuit for SPICE simulations

An equivalent circuit of the setup was used for SPICE simulations (see Figure 1). The equivalent circuit takes detector capacitance (9.2 pF), signal cable length (3.05 m), bandwidth of the amplifier (1 GHz) and imperfections of the setup (inductances and capacitances) into account. The transfer function of the whole setup has been checked and was found to introduce distortions. Thus all simulations have been convoluted with the transfer function (shown in Figure 2).

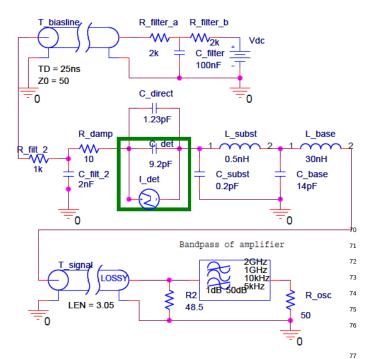


Figure 1: Equivalent circuit for SPICE simulations. Dominant el- $_{78}$ ements are the diode capacitance in parallel to the current source (marked by the rectangle), the system inductance (30 nH), the lossy transmission line (3.05 m RG-174 cable) and the band pass filtering 80 properties of the amplifier. $_{81}$

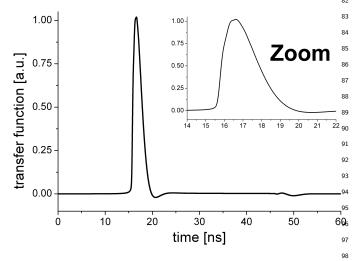


Figure 2: Transfer function derived from the SPICE simulations for $_{99}$ 9.2 pF capacitance. The inset shows a zoom of the peak structure of $_{100}$ the transfer function using the same units on the x- and y-axis.

2.2. Laser properties

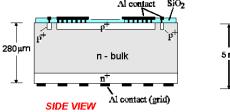
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The laser system [8] emits short and intense light pulses ¹⁰⁴ with a FWHM < 100 ps. The time resolved pulse structure ¹⁰⁵ was specified by the manufacturer. For this study laser ¹⁰⁶ light with a wavelength of 660 nm (\pm 2 nm) was used. As ¹⁰⁷ the pulse structure depends on the pulse energy, a constant energy of 140 pJ was chosen and attenuated with optical ¹⁰⁸ attenuators, which have no effect on the time structure of the pulses. 660 nm light has an attenuation length of ¹⁰⁹



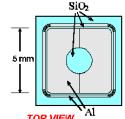


Figure 3: Geometry of the investigated sample. The diode has a thickness of 280 μm and allows injection of laser light from the junction side and opposite to the junction.

roughly 3 μm in silicon at 20°C.

The laser beam was focused to a spot with a Gaussian profile with $\sigma=10~\mu m$. In air the Rayleigh length (distance from focal point to the point where the beam radius increases by $\sqrt{2}$) is approximately 90 μm . The high index of refraction of silicon (≈ 3.6) allows to assume a constant lateral beam profile for the entire absorption path.

2.3. Investigated diode

The investigated diode was a planar p⁺nn⁺ diode fabricated by CiS [9]. The silicon used is high resistivity n-type diffusion oxygenated float zone silicon with <100> orientation manufactured by Siltronic [10]. The effective doping of the sample was calculated from a capacitance measurement as function of voltage and is 8.2×10^{11} cm⁻³. The resulting depletion voltage is 49 V with a dark current at the depletion voltage of 0.72 nA. The sample has a very low concentration of lattice defects, leading to life times in the order of milliseconds, which is many orders of magnitude larger than the longest pulse duration recorded in this work. Any trapping effects have been considered negligible.

From the measured pad capacitance of 9.23 pF and the pad area of (4.95 mm)² we obtain a thickness of 280 μm using the standard formula for a parallel plate capacitor without edge effects. For the measurement of the pad capacitance the capacitance of the guard ring to the backplane and the sensor edge is subtracted by the zero adjustment of the capacitance bridge. The remaining effect of the guard ring is estimated to be well below 1 %. The estimated uncertainty of the diode thickness is \pm 2 μm .

Mechanical measurements of the thickness yield the somewhat higher value of 287 μm but include 'dead' layers like implantations, passivations and aluminizations.

The diode has an opening on the p^+ side and an aluminum grid on the n^+ side to allow light injection. The gap between the metalization of diode guard ring is 20 μ m wide, the distance between the corresponding implantations is 10 μ m. A sketch of the diode is shown in Figure 3.

3. Simulations

For the transport simulations the classical van Roosbroeck equations are used [11].

The lifetime of the plasma cloud is determined by the 144 emission of carriers into the surrounding volume with low₁₄₅ charge carrier density. A slow movement of the center₁₄₆ of the plasma cloud results from the different probabil-147 ity to emit an electron or a hole from different parts of 148 the plasma, depending on the distance to the closest electrode. Most of the charge carriers outside of the plasma are transported in the depleted volume. The electric field in this volume (outside of the plasma) is defined by the bulk doping and the external voltage. Dominating influences in the simulation are the field induced mobility reduction, the initial cloud size and density.

3.1. Simulated physics

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The fundamental equations describing the problem are the Poisson equation and the continuity equations for elec-149 trons and holes.

$$-\nabla \cdot \epsilon \nabla w + n - p = C \tag{1}_{152}$$

$$\frac{\partial n}{\partial t} + \nabla \cdot \mu_n n \nabla \phi_n = R$$

$$\frac{\partial p}{\partial t} - \nabla \cdot \mu_p p \nabla \phi_p = R$$

$$(2)_{153}$$

$$(3)_{155}$$

$$\frac{\partial p}{\partial t} - \nabla \cdot \mu_p p \nabla \phi_p = R \tag{3}_{155}$$

Where $\epsilon = \epsilon_0 \epsilon_r$ is the dielectric permittivity, w the electrostatic potential, n and p the electron and hole density,₁₅₈ C the density of impurities, $\phi_{n,p}$ the quasi-Fermi potential₁₅₉ for electrons or holes, $\mu_{n,p}$ the charge carrier mobilities₁₆₀ and R the recombination or generation rate.

Potentials are normalized to a constant reference po-162 tential and densities to a reference density. The meaning 163 of the variables and parameters used are listed in the ap-164 pendix.

The mobility models used are summarized and dis- $_{166}$ cussed in [12]. The mobility μ depends on lattice (L),₁₆₇ ionized (I) and unionized (N) impurity scattering, carrier-168 carrier scattering (np) and the electric field, where (I), $(N)_{169}$ and (np) have the meaning of densities.

Lattice and ionized impurity scattering is modeled us-171 ing:

$$\mu_{n,p}^L = \mu_{n,p}^0 (\frac{T}{300K})^{-\alpha_{n,p}}$$
 (4)

$$\mu_{n,p}^{LI} = \frac{\mu_{n,p}^{L}}{\sqrt{1 + \frac{I}{C_{n,p}^{ref} + \frac{I}{S_{n,p}}}}}$$
(5)₁₇₆

Unionized impurity scattering is modeled using:

$$\mu^{N}(T) = \frac{0.041qm_{n,p}^{*}}{Na_{Bohr}\hbar m_{0}\epsilon_{r}} \left(\frac{2}{3}\sqrt{\frac{k_{B}T}{EN_{n,p}}} + \frac{1}{3}\sqrt{\frac{EN_{n,p}}{k_{B}T}}\right) 6^{\frac{180}{181}}_{182}$$

$$EN_{n,p} = 0.71eV \frac{m_{n,p}^*}{m_0} \left(\frac{\epsilon_0}{\epsilon}\right)^2$$
 (7)₁₈₄

Carrier-carrier scattering is implemented using the structure of Adler's model [13]:

$$\mu^{np} = \frac{\mu_{Adl1}}{\sqrt{np}\ln(1 + \mu_{Adl2}(np)^{-1/3})}$$
(8)

The total mobility is approximated by using Matthiessen's rule [14] to combine the contributions (they have the meaning of scaled inverse macroscopic cross sections Σ , the total cross-section Σ_{tot} is the sum over all Σ_i of uncorrelated scattering events i).

$$1/\mu^{LINnp} = 1/\mu^{LI} + 1/\mu^N + 1/\mu^{np} \tag{9}$$

The total mobility is reduced by velocity saturation for high values of $|\nabla \phi_{n,p}|$.

$$\mu_{n,p}^{LINnpE} = \frac{\mu_{n,p}^{LINnp}}{\left(1 + \left(\frac{\mu_{n,p}^{LINnp}|\nabla\phi_{n,p}|}{v_{out}}\right)^{\beta}\right)^{\frac{1}{\beta}}}$$
(10)

In the simulations the driving force $(\nabla \phi_{n,p})$ is used to derive the mobility reduction¹. For the sake of simplicity we call this reduction 'field induced'.

3.2. Numerical methods

The code follows the theory described in [15]. The time integration is based on variable order implicit backward differentiation formulas (BDF) with time step size and order control (see appendix).

For certain detector applications a very precise number of electron hole pairs (relative error $\ll 10^{-5}$) has to be generated in order to estimate possible charge losses in the device. In order to achieve this high precision an automated rescaling procedure is used.

The rescaling procedure uses a comparison of two integrations. For this, all external generation processes (sources, e.g. laser excitation) are parameterized in space and time. The first integration is done independent from the simulation process and results in a high precision source integral and the number of electron hole pairs that should be gen-

The second integration is executed during the simulation and uses the discrete time and space steps of the simulation for integration. The integration result is the number of generated electron hole pairs in the simulation. There is a small difference (<1%) between generated and intended number of charge carriers due to the finite step sizes and time discretization errors.

Charge carrier numbers are rescaled to the intended numbers, derived values like current are rescaled as well. In this way the required high precision generation is as-

The contact currents are evaluated by using test functions, which approximate the solutions of the related adioint problem [16]. These techniques are necessary to fulfill charge conservation requirements expected in detector design applications [17].

¹In the depleted bulk silicon this is identical to the derivation using the electric field (∇w) .

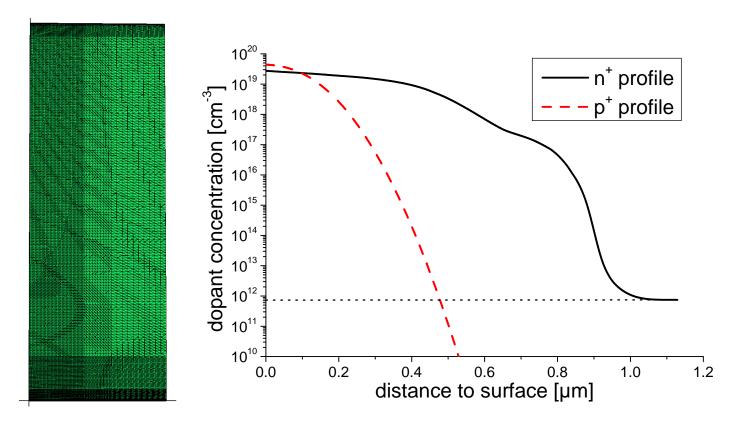


Figure 4: The left graph displays a grid of mesh size h defining the slice of a cylinder. Step sizes are $h_r = 1, ..., 4\mu m$ and $h_z = 0.2, ..., 2\mu m$. Top and bottom of the grid are defined as ohmic contacts, the boundary conditions create a cylindrical symmetry. The right graph displays doping profiles as function of depth. The tail of the n^+ profile reflects the bulk doping concentration which is marked by the dotted horizontal line.

4. Simulation parameters

A rather simple spatial domain is used to test the nu- $_{209}$ merical methods. A 10° slice of a cylinder of 280 μm height $_{210}$ and 100 μm radius is discretized by a set of tensor product $_{211}$ grids that are rotated and split in tetrahedra to obtain a $_{212}$ slightly anisotropic Delaunay grid. This allows to align the $_{213}$ edges in the main field direction and results in less points compared to isotropic grids. Thus nested grids, labeled h_{214} (22990 nodes), h/2 (91339 nodes)and h/4 (364117 nodes) are possible (see Figure 4).

Along the main drift path of the charge cloud the grid is refined (central part of the cylinder). The illuminated side of the cylinder (top or bottom) is refined as well to resolve the small initial cloud. The distribution of created charge carriers is parameterized as

$$N(x, y, z, t) = C_0 L(t) exp(f(x, y, z))$$
 (11)²²²
 $f(x, y, z) = -(x/2\sigma_x)^2 - (y/2\sigma_y)^2 - |z - z_s|/\lambda_a (12)^{223}$

with $\sigma_x = \sigma_y = 10$ µm, z_s top or bottom, $\lambda_{abs} = 3$ µm the²²⁵ absorption length of the laser light, L(t) the laser pulse²²⁶ shape and C_0 a constant to ensure that the correct num-²²⁷ ber of electron hole pairs is created. The laser pulses shape is shown in the right graph of Figure 5, its peak is very narrow (FWHM < 100 ps) and its total length is approximately 1 ns.

The p⁺ doping profile is the result of a one dimensional process simulation (compare Figure 4). It is of short range compared to the n⁺ doping profile.

The $\rm n^+$ doping profile was determined by spreading resistance measurements. The bulk doping concentration of $8.2 \times 10^{11} \rm cm^{-3}$ is marked by the dotted horizontal line in the right graph of Figure 4.

4.1. Employed mobility parameters

All results presented here are based on charge carrier mobilities reported in literature [12] (summarized in Table 2), but using $\beta_n=1$ (instead of $\beta_n=2$) for the field dependent mobility reduction (labeled literature mobility), unless mentioned otherwise. For comparison two other models have been used as well. The second model is the same as mentioned above but without field dependent mobility reduction (labeled constant mobility). The third model uses the same models for lattice, ionized and unionized impurity scattering as well as the same model for carrier-carrier scattering, but the field dependent parameters for <100> crystal orientation described in [18] were used (labeled fitted mobility, summarized in Table 3).

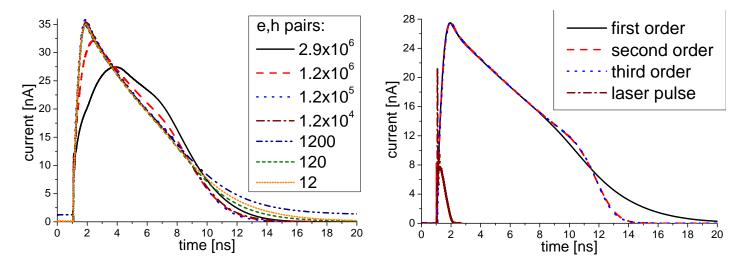


Figure 5: The left graph shows the current pulse for different numbers of charge carriers created at the junction side, rescaled to a fixed number of charge carriers (1200 electron hole pairs). For cloud sizes with more than 1.2×10^5 electron hole pairs pulse distortions due to the charge carrier density are visible. The right graph shows pulse shapes for 1200 electron hole pairs starting an the junction (high field side) and the influence of the order of the time integration scheme. For comparison the laser pulse structure is also shown. The applied voltage for both graphs is 80 V.

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5. Simulation results

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5.1. Test of the numerical methods

To test the numerical methods and the models including their parameters a set of simulations with low numbers of charge carriers was done. The simulated currents were rescaled to a fixed charge after the simulation process for comparison and are shown in the left graph of Figure 5.

Typical discretization errors are evaluated by repeat-²⁶⁸ ing computations for one number of charge carriers with ²⁶⁹ different spatial and time step sizes and a different time ²⁷⁰ integration order. Effects of different time integration or-²⁷¹ ders for junction side creation of charge carriers is shown ²⁷² in the right graph of Figure 5. Effects for charge carrier ²⁷³ creation opposite to the junction are shown in Figure 6. ²⁷⁴ The left graph of Figure 6 shows the effects of different ²⁷⁵ time integration schemes, the right graph shows the effect ²⁷⁶ of different grid sizes.

As expected the implicit Euler scheme (i.e. the first or-²⁷⁸ der time integration scheme, see appendix for details) re-²⁷⁹ sults in too much energy dissipation. This can be observed ²⁸⁰ as additional diffusion and is seen in the pulse shape of the ²⁸¹ currents shown in the right graph of Figure 5 and the left ²⁸² graph of Figure 6.

For the implicit Euler scheme the current starts to de-²⁸⁴ crease earlier due to the artificially increased diffusion and ²⁸⁵ shows a long tail.

The differences between second and third order time 287 integration schemes are small compared to the difference 288 between the implicit Euler and the higher order schemes.

As a consequence all simulations which were compared ²⁹¹ to measurements, do not use the first order scheme in the ²⁹¹ calculations.

The spatial discretization errors are checked by using the $h,\,h/2,\,$ and h/4 grids explained above. Compared with

the time discretization error of the Euler scheme the space discretization error shown in the right graph of Figure 6 is small

The influence of spatial discretization errors is considered negligible.

5.2. Interpretation of the results

When the charge cloud is created at the junction (i.e. high field) side the rise time of the current measures the cloud creation and charge carrier separation time. For small clouds the current peak corresponds to the situation where all charge carriers are drifting. In this case all holes are quickly collected at the electrode and the current is due to drifting electrons.

The almost linear reduction of the current is due to the lower average velocity at lower electric fields.

Around the 'knee' the first charge carriers reach the contact and the total number of charge carriers in the sensor drops. The strong decrease of the current represents the removal of charge carriers from the bulk volume at the contact and thus reflects the shape of the charge cloud along the drift direction. This shape is very sensitive to the enhanced diffusion of the implicit Euler scheme.

When the charge cloud is created opposite to the junction (i.e. low field) side the current shows a steep increase while the cloud it created and separates. In this case all electrons are quickly collected at the electrode and the current is due to drifting holes.

The almost linear increase of the current is due to the higher drift velocity at higher electric fields.

Around the peak the charge cloud reaches the contact and the number of charge carriers in the bulk material drops. Like in the case of illumination from the junction side the decrease of the current represents the removal of

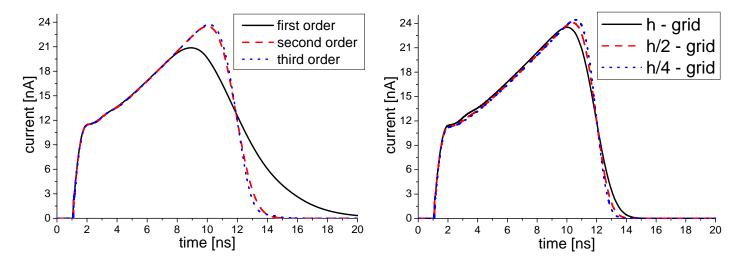


Figure 6: Comparison of typical pulses of charge carriers created opposite to the junction with different orders in the time integration scheme (left) and different grid sizes (right). Both graphs show pulses for 1200 electron hole pairs starting opposite to the junction for an applied bias of 80 V.

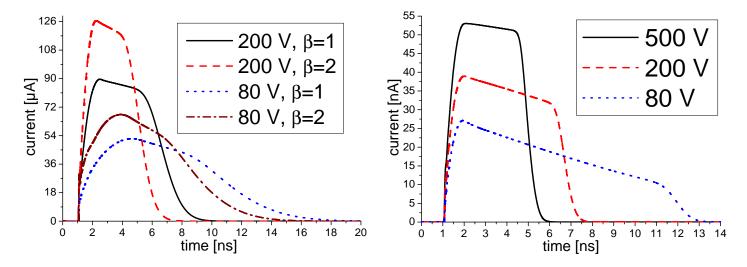


Figure 7: The left graph shows the influence of β_n on pulses for 2.9×10^6 electron hole pairs for 80 V and 200 V applied voltage. The right graph shows pulse shapes for 1200 electron hole pairs and $\beta_n = 1$ as function of the applied voltage. For both graphs the electron hole pairs were created at the junction side.

charge carriers from the sensor volume at the contact and₃₁₁ its shape is very sensitive to the enhanced diffusion of the₃₁₂ implicit Euler scheme.

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At the applied voltages neither the drift velocity of \$\frac{314}{218}\$ electrons nor the drift velocity of holes is saturated. Thus \$\frac{315}{2}\$ a charge cloud of low density traveling in the direction \$\frac{316}{2}\$ of a decreasing electrostatic field is compressed, while a low density charge cloud traveling in the other direction is \$\frac{317}{2}\$ elongated.

The mobility reduction due to large fields has a signif- $_{319}$ icant influence on the pulse shape. A strong influence of $\beta_{n,p}$ is observed as the drift velocity in the entire volume $_{321}$ is neither in the ohmic regime nor saturated. Figure 7 il- $_{322}$ lustrates the influence of the model parameter $\beta_n=1$ or $_{323}$ $\beta_n=2$. $\beta_n=1$ results in more pronounced spatial fronts $_{324}$ and $\beta_n=2$ causes a lower velocity reduction and thus

smaller flight times at high voltages.

While simulations with $\beta_n=2$ show significantly different pulses than observed in measurements, simulations with $\beta_n=1$ produce pulses which are very similar to the measurements, as shown in Figure 9 for junction side illumination for defocused laser light.

5.3. Time evolution of the spatial distribution of charge carriers

Figure 8 and the movies in the online version of this article show simulations of the time evolution of the hole density for 11×10^6 electron hole pairs and a bias of 200 V. The electron hole pairs are created by laser light of 660 nm light focused to 10 $\mu m,$ injected opposite to the p^+n junction.

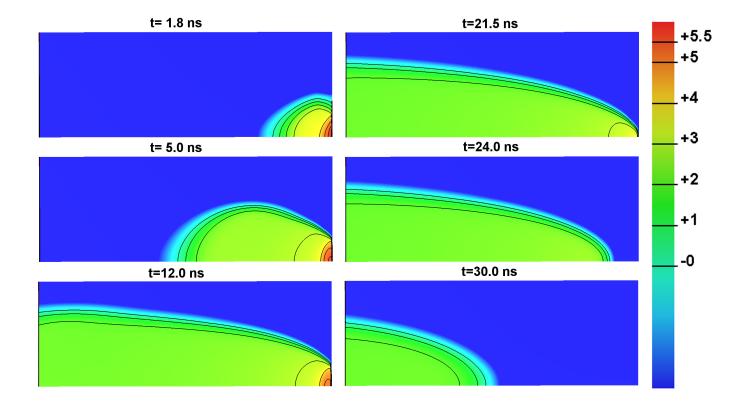


Figure 8: Evolution of a plasma cloud in space and time. The logarithm to the base of ten of the hole density divided by 10^{10} cm⁻³ is color-coded for a cut along the y axis. The simulation volume is $100 \mu m$ high (top to bottom) and $280 \mu m$ wide (left to right). 11×10^6 electrons and holes are created on the right side (opposite to the junction) and holes drift to the left. A bias of 200 V is applied.

From the drift-diffusion calculations it is concluded, that the plasma cloud does not expand, instead charge carriers are continuously released from the plasma region and thus form a conductive channel connecting both electrodes.

6. Comparison of simulations and measurements

Electron hole pairs have been created with 660 nm laser light of different intensities. The measurements for low intensities allow to verify the simulations, especially the field dependence of the mobility. For high intensity illuminations plasma effects dominate experimental results and simulations.

The observed current pulses show small ringing features (oscillations), due to the presence of inductances in the readout circuit. If the gradient on a decreasing slope is large enough the associated ringing may produce and undershoot into negative currents. This behavior is modeled by the equivalent circuit shown in Figure 1. The undershoot is neither expected nor found in the simulations before convolution with the transfer function (Figure 2).

In the simulations peak densities of $np/n_i^2 \approx 10^{10}$ are observed, at this density carrier-carrier scattering is still of small influence. Simulations without mobility reduction due to carrier-carrier scattering showed the same pulse durations and are not presented here. Artificially enhanced sequences of the same pulse for the same pulse durations and are not presented here.

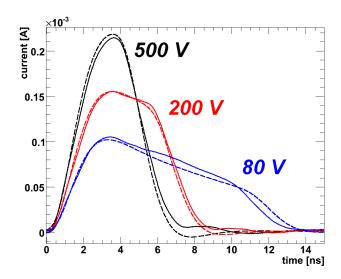


Figure 9: Results for junction side illumination using defocused laser light to avoid plasma effects. Simulations with literature mobility are shown as dashed lines and measurements as solid lines. As simulations and measurements are very similar the use of $\beta_n = 1$ is justified.

carrier-carrier scattering increases the pulse duration as expected, while the measurements show shorter pulses than the simulations.

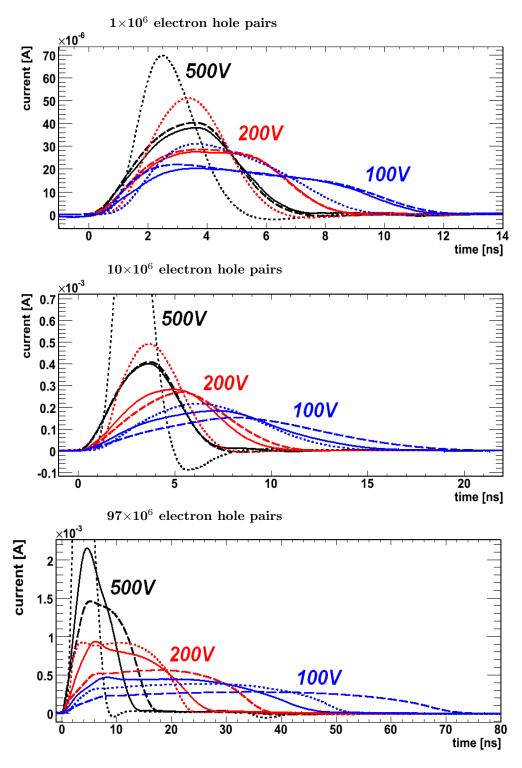


Figure 10: Measurements for junction side illumination using focused laser light (solid lines) compared to simulations. Simulations with literature mobility are shown as dashed lines, simulations with constant mobility as dotted lines. While acceptable agreement can be observed for low densities, high densities show a shorter pulse duration than the simulations. Note the different scales on the time axes.

6.1. Junction side illumination

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Injection on this side allows to check the transport 359 properties of electrons separately from those of holes, as 360 holes reach the close by electrode quickly.

Increasing the number of created carriers increases the 362

plasma effects. Inspection of the simulations shows peak values of $np/n_i^2 \approx 10^{10}$ in the plasma cloud for the case of 97×10^6 generated charge carriers.

Figures 9 and 10 show the comparison of simulated and measured currents for junction side illumination.

Simulations and measurements for low density clouds are very similar and acceptable agreement between simulation and measurement is observed for 1×10^6 electron hole pairs. Thus it can be concluded that the low density transport properties of electrons are reasonably well modeled. At higher charge carrier densities the current pulse shapes deviate from the low density case due to the lifetime of the plasma cloud. The current is determined by the release of charge carriers from the plasma cloud. The deviation between measurements and simulations increases with increasing plasma density.

As seen in Figure 10, the current rises slowly at the beginning of the pulse for 97×10^6 electron hole pairs in simulation and measurement. The rise is followed by an approximately constant current, until the final decrease shows a similar time constant as in the 10×10^6 electron hole pairs case.

In the simulations the peak at the beginning is due to the removal of the low density periphery of the cloud. The remaining high density core has an ellipsoidal shape and shrinks with time as well as the maximum density in the plasma (see Figure 8). The barycenter of the plasma slowly moves away from the junction.

Using a constant mobility speeds up the release of charge carriers from the plasma and their drift in the rest of the 418 sensor volume. Thus pulses calculated using a constant 419 mobility are systematically too short, except for the pulse 420 obtained for $97{\times}10^6$ electron hole pairs at 100 V bias, 421 which is too long by 4% of the pulse length.

6.2. Illumination opposite to the junction

This situation allows to study the transport properties 423 of the holes. Contrary to electrons, holes move towards the 424 high field region (junction). Figures 11 and 12 show the 425 comparison of simulated and measured currents for this 426 case

A qualitative agreement between simulation and mea- 428 surement is observed for the measurement with defocused 429 laser light and 1×10^6 electron hole pairs. However the simulated pulses are systematically too long. 431

For 11×10^6 electron hole pairs the 100 V and 200 V⁴³² curves show clear deviations, while at 500 V the deviations⁴³³ are at the level observed for 1×10^6 electron hole pairs. The⁴³⁴ transient behavior between the low density regime and first⁴³⁵ plasma effects observed for junction side illumination can⁴³⁶ also be observed in this case.

When 103×10^6 electron hole pairs were created, both ⁴³⁸ the simulated and the measured current pulse become very long compared to the current pulses observed for low den-⁴⁴⁰ sities. While qualitatively the simulations produce pulses with similar durations, the simulated pulses are systemat-⁴⁴² ically too long.

As in the case of illumination on the junction side, 444 using a constant mobility speeds up the release of charge 445 carriers from the plasma and their drift in the rest of the 446 sensor volume. Thus pulses calculated using a constant 447

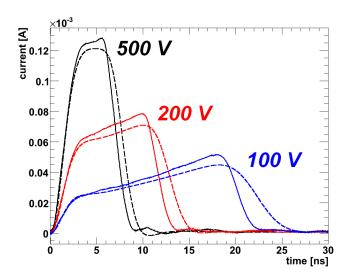


Figure 11: Results for illumination opposite to the junction using defocused laser light to avoid plasma effects. Simulations with literature mobility are shown as dashed lines and measurements as solid lines.

mobility are systematically too short as well, except for the pulse obtained for 11×10^6 electron hole pairs at 100 V bias (2.4% too long) and 103×10^6 electron hole pairs at 200 V (5.6% too long) and 100 V bias (25.9% too long).

7. Discussion and Conclusions

At low charge carrier densities the simulations for the collection of electrons (junction side illumination) agree well with the measurements. This gives us confidence in the simulation as well as in the model used for the electron transport. For the collection of holes (opposite side illumination), the simulated pulses are typically 10% longer than the measured ones. This may indicate a problem with the simulation of the charge cloud separation at low fields or with the model used for the hole transport. In [18] the experimental data has been used to determine the parameters of electron and hole transport.

High charge carrier densities result in significant distortions of the pulse shapes, both in data as well as in simulations. For the highest charge densities investigated ($\approx 10^8$ electron hole pairs) the measured pulse lengths increase by up to a factor 5 for electrons and a factor 10 for holes. The results are charge collection times up to 250 ns for a detector operated well above depletion! The simulations qualitatively describe the data and provide an understanding of the pulse shape for high charge densities: An initial rise due to the collection of charges from the periphery of the charge cloud is followed by an approximately constant current due to the release of charges from a shrinking plasma cloud.

A number of attempts have been made to understand the discrepancies.

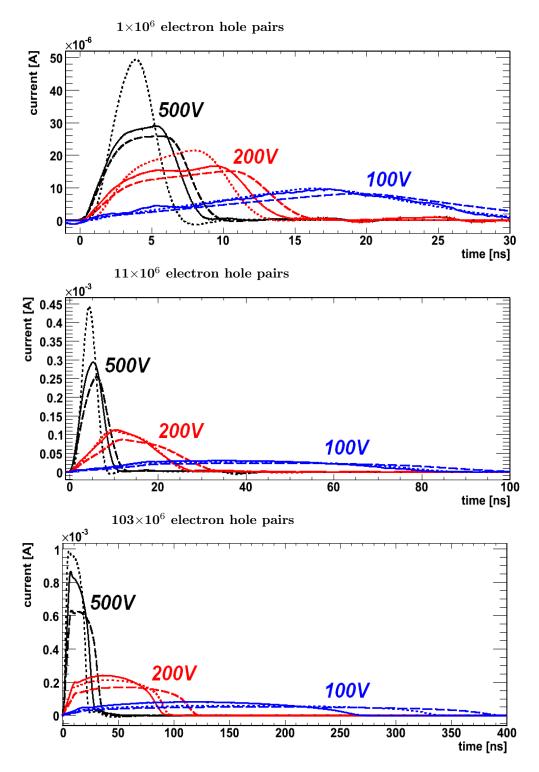


Figure 12: Measurements for injection opposite to the junction using focused laser light (solid lines) compared to simulations. Simulations with literature mobility are shown as dashed lines, simulations with constant mobility as dotted lines. Measurements systematically show a shorter pulse duration than the simulations. Note the different scales on the time axes.

To estimate the effect of having an initial charge car- $_{454}$ rier distribution which is different from the light profile, $_{455}$ simulations with different widths of the initial charge car- $_{456}$ rier distribution and absorption lengths have been done $_{457}$ for 1×10^6 and 11×10^6 electron hole pairs created opposite $_{458}$

to the junction. The results for 200 V applied bias are presented in the upper graphs of Figure 13 and 14, showing that an increase in width by 50 % or an increase in absorption length by 100 % is not sufficient to produce a pulse which is as short as the measurement.

Illumination	$N_{e,h} [10^6]$	U_{bias} [V]	duration [ns]	difference
junction side	-	500	$\emptyset/7.0/6.8$	0 / -2.9%
junction side	_	200	$\emptyset/8.5/8.4$	0 / -1.2%
junction side	_	80	$\emptyset/13.0/13.5$	0 / 3.8%
opp. to junction	-	500	$\emptyset/9.0/10.0$	Ø / 11.1%
opp. to junction	-	200	$\emptyset/13.5/15.0$	Ø / 11.1%
opp. to junction	-	100	$\emptyset/23.0/27.0$	Ø / 17.4%
junction side	1	500	5.0/7.0/7.0	-28.6% / 0.0%
junction side	1	200	6.5/9.0/9.0	-27.8% / 0.0%
junction side	1	100	10.0/12.0/12.3	-16.7% / 2.5%
junction side	10	500	5.0/7.0/7.0	-28.6% / 0.0%
junction side	10	200	8.0/11.0/12.0	-27.3% / 9.1%
junction side	10	100	15.0/17.0/20.0	-11.8% / 17.6%
junction side	97	500	8/14/18	-42.9% / 28.6%
junction side	97	200	24/28/38	-14.3% / 35.7%
junction side	97	100	52/50/75	$4.0\% \ / \ 50.0\%$
opp. to junction	1	500	7.0/9.0/10.0	-22.2% / 11.1%
opp. to junction	1	200	13/15/17	-13.3% / 13.3%
opp. to junction	1	100	31/31/38	$0.0\% \ / \ 22.6\%$
opp. to junction	11	500	9/12/14	-25% / 16.6%
opp. to junction	11	200	27/28/35	-3.6% / 25.0%
opp. to junction	11	100	87/85/100	2.4% / 17.6%
opp. to junction	103	500	25/30/35	-16.7% / 16.7%
opp. to junction	103	200	95/90/120	$5.6\% \ / \ 33.3\%$
opp. to junction	103	100	340/270/390	25.9% / 44.4%

Table 1: Pulse durations for all measurements (t_{meas}) presented in this work compared to their simulations with the literature mobility model (t_{lit}) and the constant mobility model (t_{const}) . The column labeled $N_{e,h}$ lists the number of created electron hole pairs; a '-' indicates the low density measurement and simulation. The column labeled U_{bias} lists the applied bias voltage. The column labeled duration lists $t_{const}/t_{meas}/t_{lit}$. The column labeled difference lists $(t_{const}-t_{meas})/t_{meas}$ and $(t_{lit}-t_{meas})/t_{meas}$. A ' \emptyset ' indicates that no corresponding simulation was performed. The measurements have been performed with 660 nm light focused to a Gaussian spot with $\sigma_{laser}=3$ µm on a p⁺nn⁺ diode with a thickness of 280 µm and an effective doping of 8.2×10^{11} cm⁻³.

Using literature data of the mobility, the low density $_{483}$ limit for holes (Figure 11) could not be reproduced, indi- $_{484}$ cating the need for changes in the mobility parameteriza- $_{485}$ tions. Using the fitted mobility parameterization for holes $_{486}$ the current pulse for 1×10^6 electron hole pairs could be $_{487}$ well reproduced (Figure 13, bottom).

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Although certainly not realistic, we have made simula-489 tions assuming that the mobility is independent of the elec-490 tric field (constant mobility model). The pulses obtained 491 are systematically shorter than the measured ones (except₄₉₂ for the highest intensity at low bias voltage). However493 the mobility model from the literature and the constant₄₉₄ mobility model give the interval in which the measured 495 pulse durations are found. Table 1 summarizes the re-496 sults. The results assuming the constant mobility model₄₉₇ are also presented in Figs. 10 and 12, and in the upper 498 graphs of Figs. 13 and 14. They show, that the release of 499 charge carriers from the plasma cloud can be significantly 500 accelerated, when the diffusion parameter, which is related 501 in our simulation to the mobility by the Einstein relation₅₀₂ $(D_{n,p} = \mu_{n,p}k_BT/q)$, does not decrease with increasing 503 field. Combined with the increased drift velocity of the 504 charge carriers this results in almost all cases in simulated current pulses, which are shorter than the measured ones.

This observation suggests that the Einstein relation between mobility and diffusion, which is valid only in the equilibrium case, has to be modified at high fields and/or at high charge carrier densities.

The possible effects of Fermi-Dirac statistics (see [22], [23]) were estimated and the expected influence on the pulse length should be studied, especially because the Einstein relation $(D=\mu k_BT/q)$ would be replaced by a density dependent one. Hence the interplay of drift and diffusion will be modified.

The van Roosbroeck equations used in the simulations describe the situation in the diode for low density charge clouds well, however in situations with high densities gradients may violate assumptions made in the derivation of the drift-diffusion approximation (compare [12] for a short discussion).

Optical photons of 660 nm wavelength (1.87 eV) produce so called hot charge carriers, as the band gap of silicon is approximately 1.12 eV. The simulation assumes charge carriers in thermal equilibrium with the crystal lattice, which is justified, as the thermalization of the hot carriers is usually very fast compared to the pulse duration.

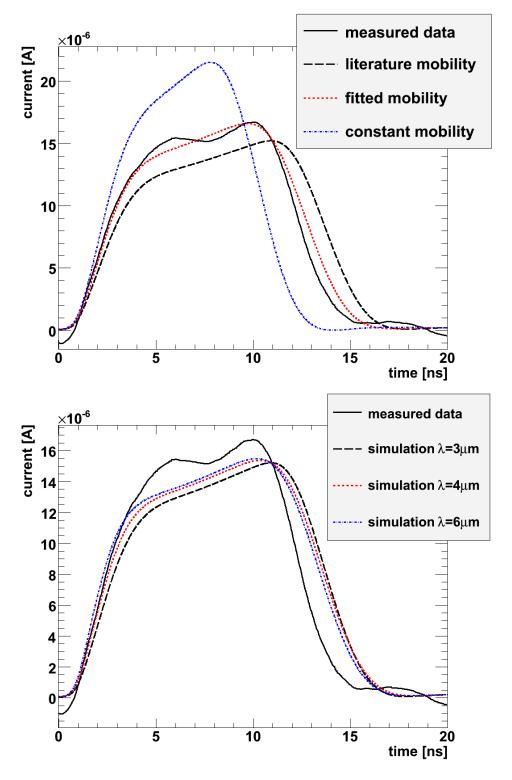


Figure 13: Effects of different parameters on the simulated current pulses for 1×10^6 electron hole pairs at 200 V applied voltage. The upper graph shows the influence of different mobility models. The lower graph shows the influence of different distributions of the initial charge cloud. Although lower density clouds dissolve faster, the effects of different attenuation lengths are small compared to the effects of a constant mobility model.

8. Summary

with emphasis on the impact on sensor performance of detectors for experiments at the European XFEL.

A simulation program was developed to model the ${\rm trans}_{510}$ port of charge carriers for high densities in silicon sensors

The numerical stability and applicability for sensor de-

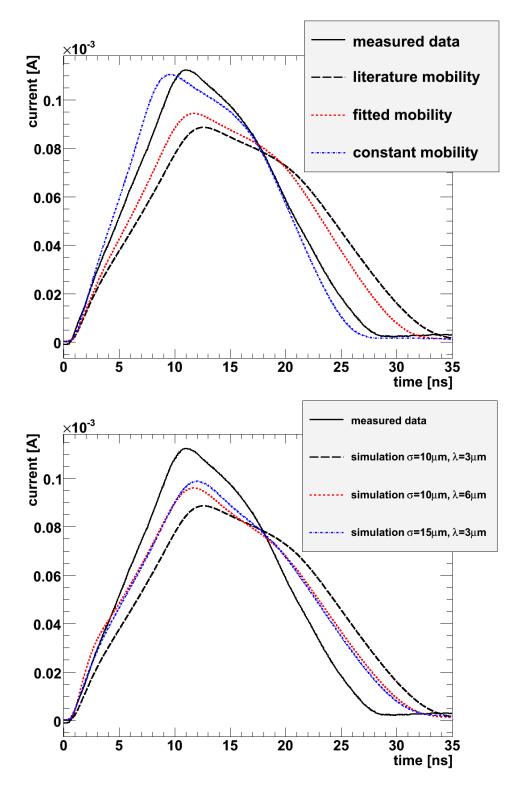


Figure 14: Effects of different parameters on the simulated current pulses for 11×10^6 electron hole pairs at 200 V applied voltage. The upper graph shows the influence of different mobility models. The lower graph shows the influence of different distributions of the initial charge cloud. Although lower density clouds dissolve faster, the effects of different initial distributions are small compared to the effects of a constant mobility model.

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sign purposes has been demonstrated. 511

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As a result of the comparison of measurements and 515simulations it is concluded that the observed plasma ef-516 highest intensity, two different sets of mobility models can

fects cannot be described by using the mobility and diffusion models in literature. It is shown that, except for the

Parameter	Value	
ϵ_r	11.67	
μ_n^0	$1448 \text{ cm}^2/\text{Vs}$	
$\mu_n^0 \ \mu_p^0$	$495 \text{ cm}^2/\text{Vs}$	
α_n	2.33	
α_p	2.23	
I	n_i	
C_n^{ref}	$3 \times 10^{16} \text{ cm}^{-3}$	
$C_n^{ref} \ C_p^{ref} \ S_n$	$4 \times 10^{16} \text{ cm}^{-3}$	
\dot{S}_n	350	
S_p	81	
\dot{N}	$\sum_{i} C_{i} $	
μ_{Adl1}	$\frac{\sum_{i} C_{i} }{\frac{1.04 \times 10^{21}}{cmVs} (\frac{T}{300K})^{3/2}} \frac{1.45 \times 10^{13}}{cm^{2}} (\frac{T}{300K})^{2}$	
μ_{Adl2}	$\frac{7.45 \times 10^{13}}{cm^2} \left(\frac{T}{300K}\right)^2$	
v_{sat_n}	$1.1 \times 10^7 \mathrm{cm/s}$	
v_{sat_p}	$0.95 \times 10^7 \text{ cm/s}$	
β_n	1 or 2	
eta_p	1	

Table 2: Parameters used in the mobility parameterization. Parameters are quotes from [12], β_n has been set to unity.

be used to simulate pulses which are either systematically $_{553}$ longer or systematically shorter than the measurements $_{554}$ and thus allows to estimate the minimum and the maxi- $_{555}$ mum of the pulse duration.

In spite of the discussed discrepancies the simulation₅₅₆ program is a valuable tool for the design and optimization of sensors and readout electronics for the European XFEL.

Combining the effects of Fermi-Dirac statistics in the diffusion process, variations in the parameters of the initial distribution of charge carriers and an optimized mobility model it may be possible to provide simulations which reproduce the measurements reasonably well for all intensities with a single, unified set of parameters.

9. Acknowledgments

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10. Appendix A

10.1. Simulation parameters and derived values

All symbols and their meaning are listed in Table 4. All potentials in this table are normalized to a constant refer-557 ence potential ($U_T = k_B T_0/q \approx 1/40V$ at room tempera-558 ture), all densities to a reference density ($n_{ref} = 10^{10} \text{cm}^{-3}$ 389 n_i).

Parameter	Value
$\mu_p^0(T)$	$474 \frac{cm^2}{Vs} T_{rel}^{-2.619}$
$v_{sat_p}(T)$	$0.94 \times 10^{7} \frac{cm}{s} T_{rel}^{-0.226}$
$\beta_p(\mathrm{T})$	$1.181 \frac{T_{rel}}{T_{rel}}^{0.644}$
$\mu_n^0(T)$	$1440 \frac{cm^2}{V_c} T_{rel}^{-2.26}$
$v_{sat_n}(T)$	$1.054 \times 10^{7} \frac{cm}{T_{rel}} T_{rel}^{-0.602}$
$\beta_n(T)$	$0.992 T_{rel}^{s} 0.572$

Table 3: Parameters from [18] used for the parameterization labeled 'fitted mobility'. The abbreviation $T_{rel}=\frac{T}{300K}$ has been used to improve legibility.

10.2. Assumptions on the simulation domain, grids, and space discretization

The simulation space is defined on a bounded, polyhedral domain $\Omega \subset \mathbb{R}^3$ with a boundary $\partial \Omega = \Gamma_D \cup \Gamma_N$. Γ_D denotes the Dirichlet part of the boundary. It is closed, has a positive measure and describes ohmic contacts. The Neumann part Γ_N describes insulating boundary parts or symmetries. The solutions (w(t), n(t), p(t)) are defined in $S \times \Omega$ with the time interval $S = (0, t_{end})$ and $(w(0) = w_0, n(0) = n_0, p(0) = p_0)$ the initial values. The domain is discretized by a boundary conforming, tetrahedral Delaunay mesh and the usual Scharfetter–Gummel discretization is used (compare [15], [19]).

10.3. Time integration

For the implicit Euler scheme dissipativity can be proven. It guarantees positive solutions on any Delaunay grid and for any time step. This cannot be expected for higher order schemes in general. Hence the related family of backward differentiation methods (BDF) is used to reduce dissipation while the order control handles the observed oscillations in space and time. Let

$$y'(t) = f(t, y(t)), \quad y(t_0) = y_0$$
 (13)

denote a nonlinear first order initial value problem with the initial value y_0 . The BDF formulas for order m=1,2,3 (m=1 implicit Euler) at time step $y(t_k)=y_k$ with constant step size τ are:

$$m = 1: y_{k+1} - y_k = \tau f(t_{k+1}, y_{k+1})$$
(14)

$$m = 2: \frac{3}{2}y_{k+1} - 2y_k + \frac{1}{2}y_{k-1} = \tau f(t_{k+1}, y_{k+1})$$
 (15)

$$m = 3: \frac{11}{6}y_{k+1} - 3y_k + \frac{3}{2}y_{k-1} - \frac{1}{3}y_{k-2} = \tau f(t_{k+1}, y_{k+1})$$
(16)

For m=1,2 the formulas are A-stable (stable for the linear test problem and eigenvalues in the left half plane, the cases m=3,4 are still stable for a sector of 88° , 72° around the negative real axes), see [24] and literature cited therein. The BDF formulas can be modified for variable step size. Time step size control is based on predictor-corrector differences of functionals, like free energy, dissipation rate, one selected contact current, sources, and

Parameter	Meaning
t	time
x	position in space (vector)
ϵ_0	dielectric constant
$\epsilon = \epsilon_0 \epsilon_r$	dielectric permittivity
k_B	Boltzmann constant
q	elementary charge
m_0	electron mass
$m_{n,p}^*$	effective mass of electron or hole
a_{Bor}	Bohr radius
\hbar	reduced Planck constant
T	lattice temperature
$T_0 = 293.15K$	reference temperature
w	electrostatic potential
$\phi_n = w - \log n / n_i$	quasi-Fermi potential for electrons
$\phi_p = w + \log p / n_i$	quasi-Fermi potential for holes
$n = n_i e^{w - \phi_n}$	electron density
$p = n_i e^{\phi_p - w}$	hole density
C	density of impurities
$\tau_n = \tau_p = 10^{-3} \mathrm{s}$	Shockley-Read-Hall recombination lifetime
$p_0 = n_0 = n_i$	intrinsic charge carrier density
$R = \frac{1}{\tau_n p_0 + \tau_p n_0 + \tau_n p + \tau_p n} (n_i^2 - np)$	recombination / generation rate
$\mu_{n,p} > 0$	carrier mobilities
$D_{n,p} = \mu_{n,p} k_B T / q$	Einstein relation

Table 4: Parameters and derived values used in the simulations.

their deviations from a polynomial predictor and the num-593 ber of Newton steps needed to solve the nonlinear equa-594 tions. The variable time integration order is controlled by 595 testing different order predictors against the computed so-596 lution at the present time step. The order of integration 597 of the next time step is defined by the predictor with min-598 imal error. Time step rejections are based on the local 599 truncation errors and the number of Newton steps. A re-600 jection is combined with order reduction. The maximum₆₀₁ order can be specified. The identical technique is used to 602 apply continuation methods (the continuation parameter 603 (\tilde{t}) replaces time (t)) with respect to the boundary val-604 ues or model parameters, because it is often impossible 605 to reach large applied voltages directly from the uniquely 606 defined equilibrium. $\tilde{t}=0$ corresponds to a state with 607 known solution, $\tilde{t}=1$ to the wanted state with an un-608 known solution. The only difference, with respect to time 609 integration, is taking truncation errors not into account,610 because a sequence of stationary solutions is constructed. 611 The predictor is chosen such that the positivity of the den-612 sity variables is preserved.

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Each time step requires the precise solution of one nonlinear system of equations by Newton's method. Charge conservation is lost accordingly due to the errors introduced in the solution of the nonlinear equations.

10.4. Solution of the linear and nonlinear equations

The discrete nonlinear system of equations is Newton linearized by computing the functions and their derivatives

of all dependencies, including the derivatives of parameters, together. Hence, common expressions are reused in the function and the Jacobian. The solution of the nonlinear equations is controlled by the L^{∞} -norm of all potential updates, hence it is precise for low densities, too.

The linear systems are solved by a combination of direct [20], iterative methods [21] and primary and secondary preconditioners. The primary preconditioner avoids the factorization of the complete Jacobian by approximating the main dependencies by scalar equations on the whole domain. The secondary preconditioners solve local systems to include the missing couplings (avalanche, small time steps, strong recombination etc.) for all variables at a given grid point or very small subsets of the grid.

This allows to avoid the factorization of the complete Jacobian, hence to reduce memory requirements and the operations needed while one is still getting quadratic convergence of the Newton process.

The main algorithms defining the limits of the applications are grid generation and the solution of the linear systems.

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